

The University of Manchester



Novel architectures for graphene spintronics



Ivan Jesus Vera-Marun

Nonlocal spin geometry

Novel spin functionality in future electronics (ITRS) Separate charge from other degrees of freedom All-electrical approach



What can we learn?

Double-gated encapsulated bilayer

Nature of spin relaxation + spin FET action

Vertical spin transport junctions

Probe proximity to ferromagnetic metals

State of the art: Groningen group



- Partially encapsulated graphene [1]
- $\mu \approx 23000 \text{ cm}^2/\text{Vs}$ at 4.2 K
- Outer regions affect spin transport



- First fully encapsulated w SL h-BN [2]
- $\mu \approx 8600 \text{ cm}^2/\text{Vs}$ at RT
- Low yield (only one made)

[1] M.H.D. Guimarães, P.J. Zomer, J. Ingla-Aynés, J.C. Brant, N. Tombros, and B.J. van Wees, Phys. Rev. Lett. **113**, 086602 (2014)
[2] M. Gurram, S. Omar, S. Zihlmann, P. Makk, C. Schönenberger, and B. J. van Wees, Phys. Rev. B **93**, 115441 (2016)

State of the art: Aachen group



- Bottom –up fabrication technique
- $\mu \approx 20000$ cm²/Vs at RT (best quality)
- MgO tunnel barrier exposed after deposition, fixed architecture

M. Drogeler, F. Volmer, M. Wolter, B. Terrés, K. Watanabe, T. Taniguchi, ... and B. Beschoten, Nano Lett. **14**, 6050 (2014) M. Drogeler, C. Franzen, F. Volmer, T. Pohlmann, L. Banszerus, M. Wolter, ... and B. Beschoten, Nano Lett. **16**, 3533 (2016)

Novel high-quality architecture

Flexible achitecture based on pre-patterned top hBN Series of fully encapsulated regions + contact regions Large diffusion lengths (6 μ m @ RT, 10 μ m @ 2 K)



A. Avsar, I. J. Vera-Marun, J. Y. Tan, G. K. W. Koon, K. Watanabe, T. Taniguchi, S. Adam, and B. Ozyilmaz, "Electronic Spin Transport in Dual-Gated Bilayer Graphene," NPG Asia Materials 8, e274 (2016)

Effect of hBN encapsulation

Non-encapsulated: similar to BLG on SiO₂

→ substrate issues such as roughness & charged impurities not the main source of spin relaxation

Encapsulated: 5x spin lifetime, 4x spin signal

→ Protection against residues during fabrication
 → Contacts not the main limitation





Recent spin relaxation mechanism: resonant impurity scattering



Kochan, D., Gmitra, M. & Fabian, J. Spin Relaxation Mechanism in Graphene: Resonant Scattering by Magnetic Impurities. Phys. Rev. Lett. **112,** 116602 (2014).

Non-monotonic energy dependence of spin relaxation time

Magnetic impurities also evidenced by weak localization experiments

Phys. Rev. Lett. 110, 156601 (2013)



Recent spin relaxation mechanism: reinforced Dyakonov-Perel

Only Dyakonov-Perel mechanism and e-h puddles (no magnetic impurities)

Non-monotonic energy dependence of τ_s for high-quality bilayer graphene





Van Tuan, D., Adam, S. & Roche, S. Spin dynamics in bilayer graphene: Role of electron-hole puddles and Dyakonov-Perel mechanism. Phys. Rev. B 94, 041405(R) (2016)

Van Tuan, D., Ortmann, F., Cummings, A. W., Soriano, D. & Roche, S. Spin dynamics and relaxation in graphene dictated by electron-hole puddles. Scientific Reports 6, 21046 (2016)

Spin Transport in BLG



Kochan, D., Irmer, S., Gmitra, M. & Fabian, J. Resonant Scattering by Magnetic Impurities as a Model for Spin Relaxation in Bilayer Graphene. Phys. Rev. Lett. **115**, 196601 (2015).

Spin Transport in dual-gated BLG

 $\mu \approx 24000 \text{ cm}^2/\text{Vs} @ 2\text{K}$

Local control of band-gap (#5) has no affect on nonlocal spin transport

A gap in the nonlocal region (#6) modulates the spin signal \rightarrow spin FET



1000

Resistance (Ω)

4000

5000

2000 3000



Spin Transport in dual-gated BLG

- Modulation >10x spin FET in presence of band-gap @ 2K
- Large $\lambda \sim 10 \ \mu m$, $\tau \sim 0.5 \ ns \rightarrow$ no additional spin scattering
- $\mu \approx 24000 \text{ cm}^2/\text{Vs}$ (best quality)



Take-home message (1)

Key role of residues & adsorbates, not substrate or contacts

First observation of non-monotonic energy dependence for BLG spin lifetime, consistent with recent models

Spin signal modulation > 10x via FET action

A. Avsar, I. J. Vera-Marun, J. Y. Tan, G. K. W. Koon, K. Watanabe, T. Taniguchi, S. Adam, and B. Ozyilmaz, "Electronic Spin Transport in Dual-Gated Bilayer Graphene," NPG Asia Materials 8, e274 (2016)



Vertical devices: perfect spin filter?



V. M. Karpan et al., PHYS. REV. LETT. 99, 176602 (2007) and PHYS. REV. B 78, 195419 (2008) (Co or Ni, graphene spacers) Oleg. V. Yazyev and A. Pasquarello, PHYS. REV. B 80, 035408 (2009) (Co, Ni or Fe, graphene or BN spacers)

Vertical devices: perfect spin filter?



✓ 100% MR expected for few-layer graphene

V. M. Karpan et al., PHYS. REV. LETT. 99, 176602 (2007) ; PHYS. REV. B 78, 195419 (2008)

Earlier experiments: monolayer spacer



far below theoretical predictions

Left to right:

E. Cobas et al. (Naval Res. Labs), NANO LETT. 12, 3000-3004 (2012) (possible oxidation of the ferromagnet) Wan Li et al. (Cornell), PHYS. REV. B 89, 184418 (2014) (no oxidation) Jae-Hyun Park and Hu-Jong Lee, PHYS. REV. B 89, 165417 (2014) (no oxidation)

Proximity-induced spin splitting predicted and observed experimentally



\sim 0.2T B_{exch} for graphene on YIG from lateral spin transport

J.C. Leutenantsmeyer et al, 2D Materials 4, 014001 (2017)



>14 T magnetic exchange field in graphene on EuS seen from spin Hall effect

P. Wei et al, Nature Mater. DOI: 10.1038/NMAT4603

✓ theory predicts ~50-80 meV spin splitting in graphene in proximity to ferromagnets

Yang, H. X. *et al. Phys. Rev. Lett.* **110**, 046603 (2013).

 expect that the combined effect of doping and proximity-induced spin splitting will determine FM/graphene/FM device behaviour

Vertical FM-graphene-FM junctions with 1 to 4 layers of graphene



 ✓ same device architecture, same junction dimensions etc, only change the number of graphene layers



 \checkmark tested with BN as a std barrier ~10% P

Different behaviour for mono and bi/tri-layers



monolayer graphene: good spacer but small MR, similar to earlier studies;
 Bi- and trilayer: MR INVERSION after optimizing the FM/G contact

Graphene layers adjacent to different FM metals become different weak ferromagnets



experimental data consistent with the combined effect of doping and proximity-induced spin splitting

What about doping from the metal and proximity-induced spin splitting?



- ✓ doping of graphene by metal contacts is well known
- \checkmark doping by Co and NiFe confirmed in our experiments

Graphene layers adjacent to different FM metals become different weak ferromagnets



- \checkmark spin inversion back to positive MR under small bias, ~100 meV
- \checkmark corresponds to the Fermi level shift due to doping by Co

Take-home message (2)

- monolayer graphene acts as efficient vertical spacer but does not provide significant MR
- bi- or tri-layer graphene: layers adjacent to FM electrodes become weak ferromagnets determining device behaviour
- *implication:*



Pablo Asshoff

Jose Sambricio Artem Mishchenko Andre Geim **Irina Grigorieva**

Aidan Rooney Alexander Rakowski Sarah Haigh Sergey Slizovskiy Ernest Hill **Vladimir Falko**



Asshoff, P. *et al.* Magnetoresistance of vertical Co-graphene-NiFe junctions controlled by charge transfer and proximityinduced spin splitting in graphene. *2D Mater.* (2017)





Thank you for your attention

